

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	576296	Toshiba.as.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/27 08:25
L2	4105	(conductor or conducting or conductive) near (member or support or portion) near8 (insulating or insulator or dielectric or passivation or insulated or IMD or (inter-layer near dielectric)) same (opening or trench)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/27 08:28
L4	38	1 and 2	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/27 08:27
L5	376533	fujitsu.as.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/27 08:27
L6	30	2 and 5	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/27 08:27
L7	353	2 and (silicide or siliciding or salicide)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/27 08:28
L8	323	7 and ((@ad<"20021226") or (@rlad<"20021226"))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/27 08:29